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**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

<b>In Re Application of:</b> Divakaruni et al.	<b>Conf. No.:</b> 1387
<b>Serial No.:</b> 10/707,388	<b>Art Unit:</b> 2891
<b>Filed:</b> 12/10/2003	<b>Dkt. #:</b> FLS920030274US1 (IBMF-0032)
<b>Title:</b> SILICIDE RESISTOR IN BEOL LAYER OF SEMICONDUCTOR DEVICE AND METHOD	<b>Examiner:</b> Fulk, Steven J.

**COMMISSIONER FOR PATENTS**

**DESTINATION FACSIMILE NUMBER:** 703-872-9306

Transmitted herewith is: **Response to Restriction Requirement in 5 pages**  
in the above identified application.

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**Title:** SILICIDE RESISTOR IN BEOL  
LAYER OF SEMICONDUCTOR  
DEVICE AND METHOD

**Examiner:** Fulk, Steven J.

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**RESPONSE TO RESTRICTION REQUIREMENT**

Sir:

**I. INTRODUCTORY COMMENTS**

This paper is being filed in response to the Restriction Requirement dated June 9, 2005.

Applicant hereby provisionally elects Group III, claims 12-20, with traverse.